



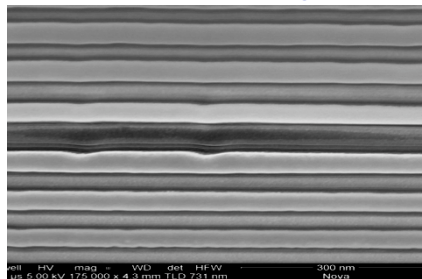
# Enhanced spontaneous emission rate in visible III-nitride LEDs using 3D photonic crystal cavities.

Project Manager: James Hudgens

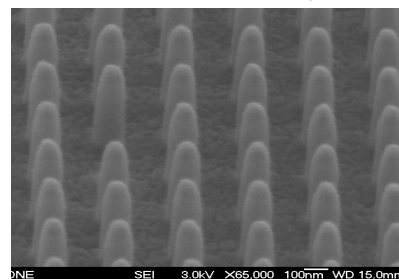
Principal Investigator: Arthur Fischer

Investment area: Electronics and photonics

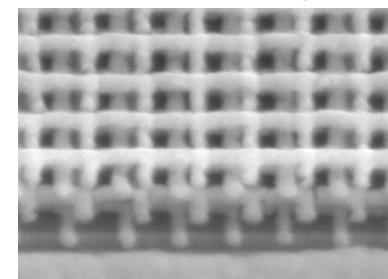
1D Photonic crystal



2D Photonic crystal



3D Photonic crystal

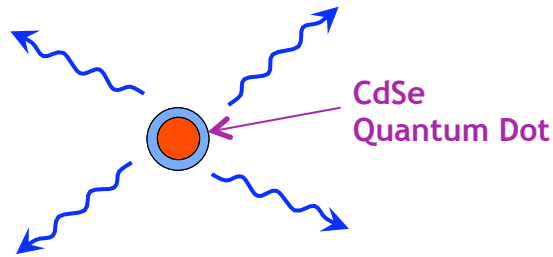


**Co-investigators: Ganesh Subramania, Ting Shan Luk, Dan Koleske, Yun-Ju Lee, Qiming Li, George Wang, Kris Fullmer, and Anthony Coley.**

Sandia is a multiprogram laboratory operated by Sandia Corporation, a Lockheed Martin Company, for the United States Department of Energy under contract DE-AC04-94AL85000.

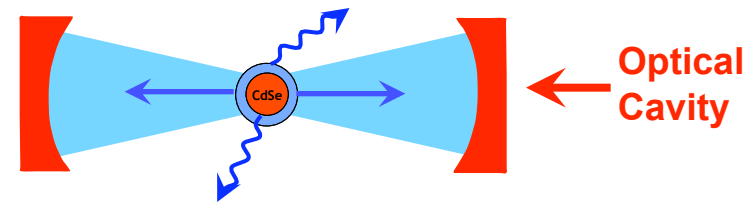
# Photonic Density of States and Light Emission

Emitter in free space



- Emitter couples to free space radiation modes
- Emitter decays with natural, fixed radiative rate ( $R_r$ )

Emitter in environment with altered photonic density of states



- Emitter couples to different radiation modes
- Radiative rate can be increased or decreased
- Photonic crystals, surface plasmons, etc...

**Fermi's Golden Rule:**

$$\lambda_{if} = \frac{2\pi}{\hbar} |M_{if}|^2 \rho_f$$

Transition Probability  $\nearrow$   $\lambda_{if}$   $\nwarrow$  Matrix Element  $\nearrow$   $M_{if}$   $\nwarrow$  Density of Final States  $\rho_f$

**Purcell Effect:**

$$F = \frac{3Q_m g (\lambda / 2n)^3}{2\pi V_{eff}}$$

$n$  = index  
 $g$  = degeneracy  
 $\lambda$  = wavelength  
 $Q$  = quality factor  
 $V$  = mode volume

**Ultimate control over when and if a photon is emitted !**

# 3D photonic crystal: density of states

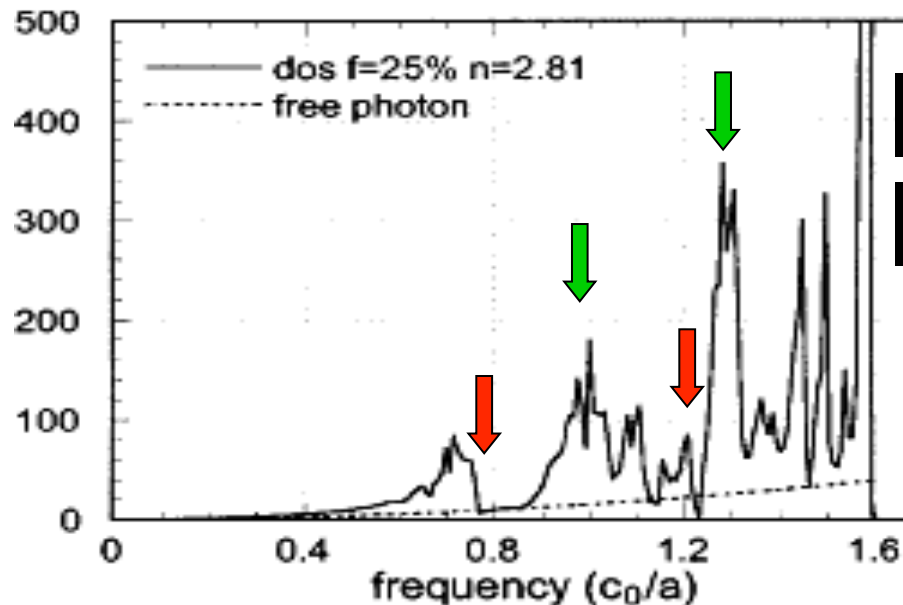
**Radiative decay rate**  
(dipole in a PC at coordinate 'r')

$$\Gamma_{\text{rad}}(\mathbf{r}) = \frac{\pi \omega \mu^2}{3 \hbar \epsilon_0} N_{\text{rad}}(\mathbf{r}, \mathbf{d}, \omega)$$

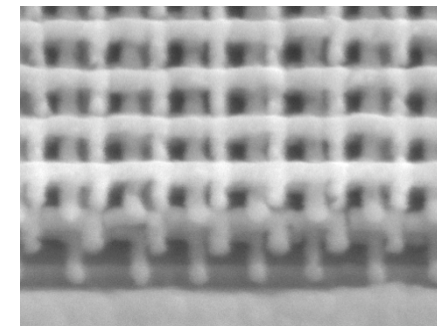
**Local radiative  
density of states  
(LRDOS)**

$$N_{\text{rad}}(\mathbf{r}, \mathbf{d}, \omega) = \frac{1}{\epsilon(\mathbf{r})} \sum_{n,k} 2\omega \delta(\omega^2 - \omega_{n,k}^2) |\mathbf{d} \cdot \mathbf{A}_{n,k}(\mathbf{r})|^2$$
$$\mathbf{A}_{n,k}(\mathbf{r}) = (\nabla \times \mathbf{H}_{n,k}(\mathbf{r})) / (\sqrt{\epsilon(\mathbf{r})} i\omega_{n,k})$$

**Photon Density of States in a 3D PC\***



**3D photonic crystal**



❖ **Enhancement**

❖ **Suppression**

- 3D PCs offers complete light control
- Density of states is position dependent
- Emitter placement inside PC is crucial

\*T.Suzuki et. al., JOSA-B, **12**, 570 (1995)

# Light Control In Nature Via Nanostructuring

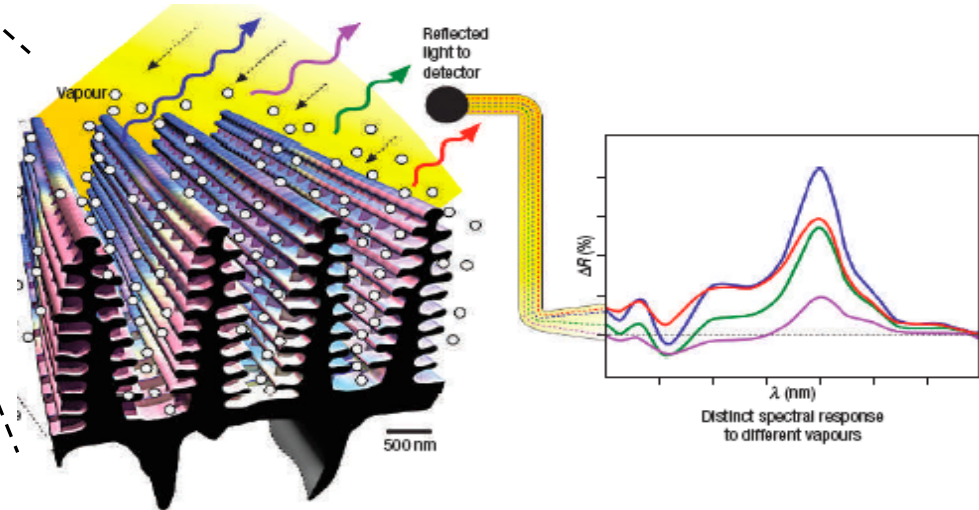
## Morpho Butterfly

(M. Sulkowskyi)



(M. menelaus)

- Photonic Crystal structures in butterfly wings.
- Color response highly sensitive to different vapors
- Signals by giving off colors by strong reflection of sunlight : visible half mile away



Passive control of light sources to suit one's requirements

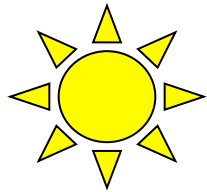
\* R.A. Potyrailo et. al. , Nature Photonics, 1, 123 (2007)



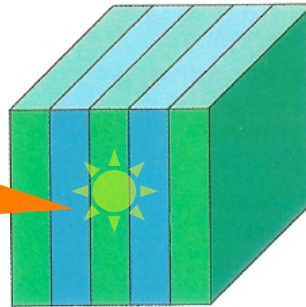
# Light emission control with photonic crystals

## Photonic Crystal Nanostructures

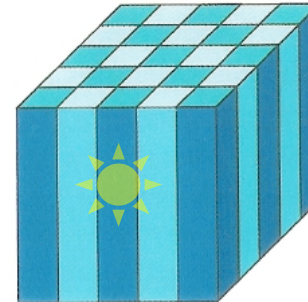
**Light Sources**  
(QDs, Qwires, thermal)



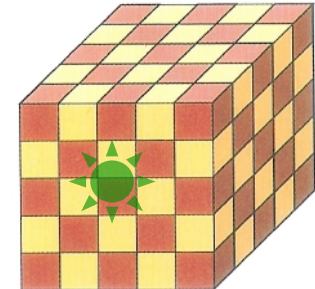
**1D**



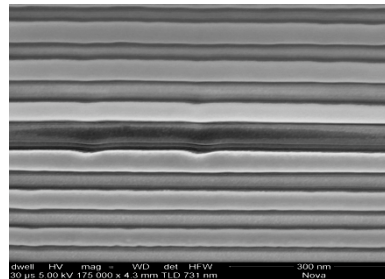
**2D**



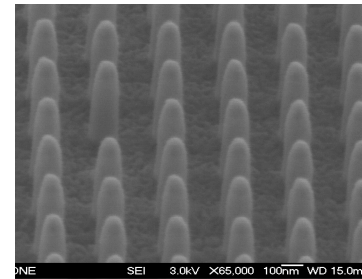
**3D**



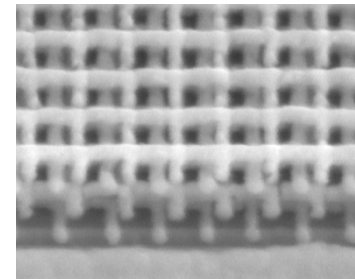
**Modify emission behavior:** Sources with novel and improved functionalities



HfO<sub>2</sub>/SiO<sub>2</sub> DBR cavity



Array of TiO<sub>2</sub> rods

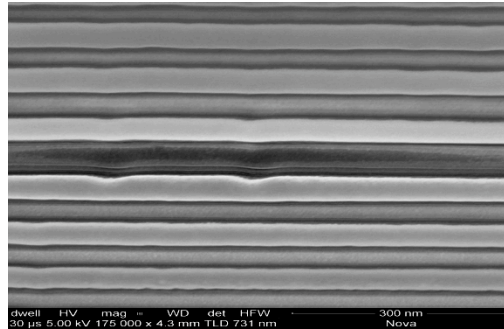


TiO<sub>2</sub> logpile PC

- High brightness/efficiency
- Tunable
- Directional, compact
- Anti-bunched
- Entangled

# 1D microcavity with GaN emitter

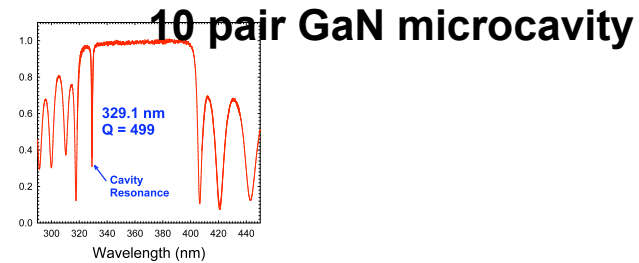
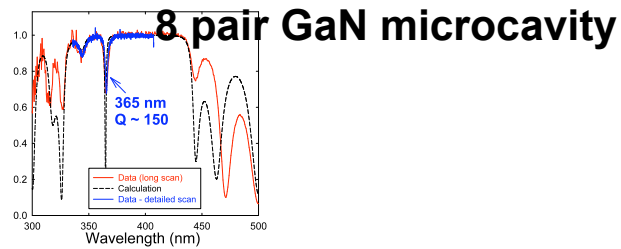
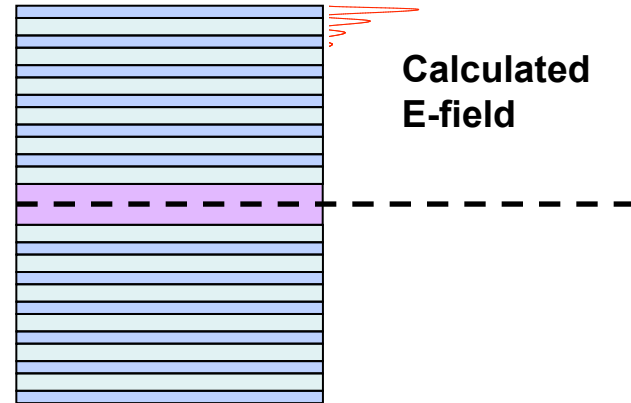
FIB-SEM image → 1D HfO<sub>2</sub>/SiO<sub>2</sub> cavity



SiO<sub>2</sub>/HfO<sub>2</sub>  
DBR

GaN  
epilayer

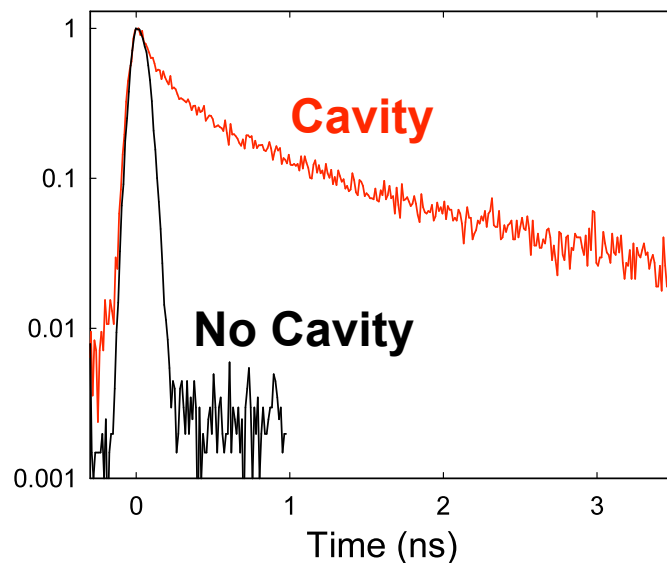
SiO<sub>2</sub>/HfO<sub>2</sub>  
DBR



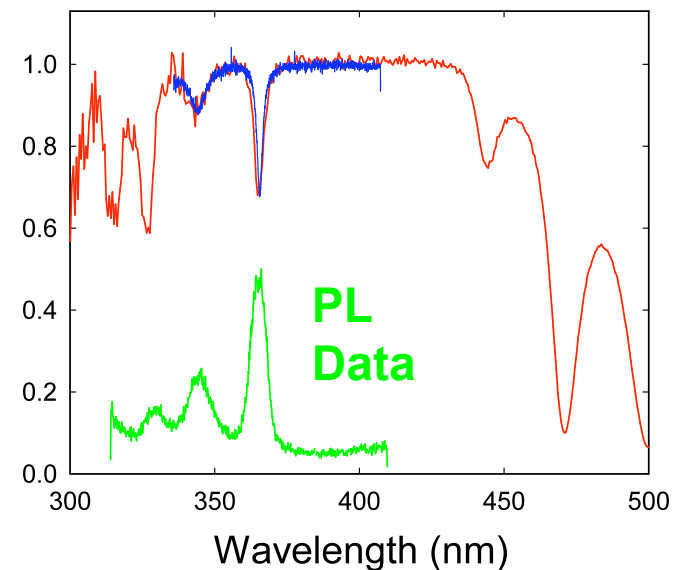
# 1D microcavity with GaN emitter: photoluminescence

- Laser-lift-off process is used to remove sapphire substrate
- 8 pair  $\text{SiO}_2/\text{HfO}_2$  mirror used to form cavity
- GaN high Q cavities can lead to exciting new physics studies
  - Strong coupling, polaritons
  - Room temperature Bose-Einstein condensates
- **DBR microcavity suppresses emission from GaN epilayer**
- **Dramatic change in lifetime observed**

Time-resolved Photoluminescence

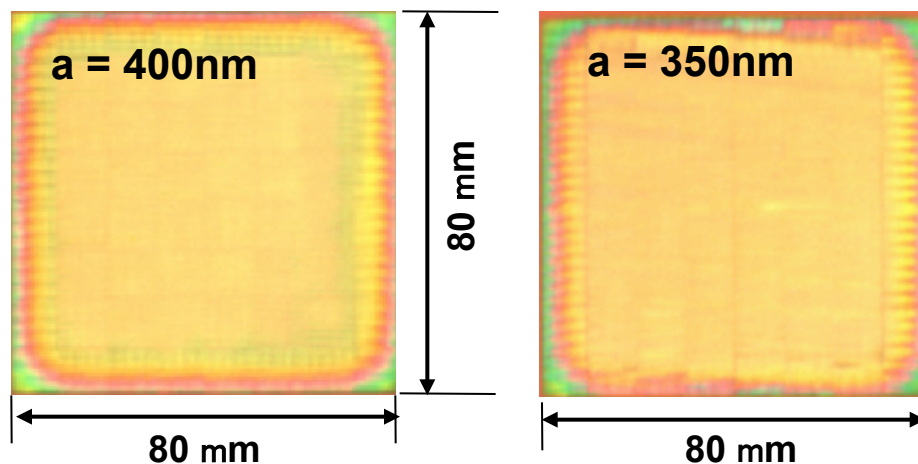


Time-integrated Photoluminescence

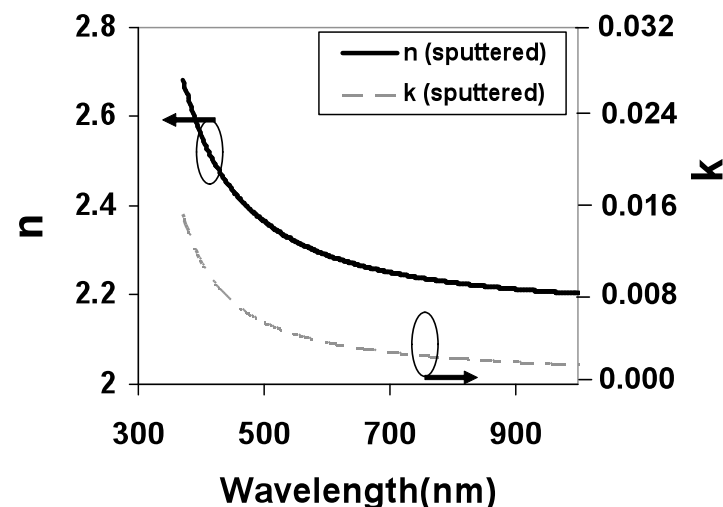


# Visible TiO<sub>2</sub> Logpile 3D Photonic Crystals

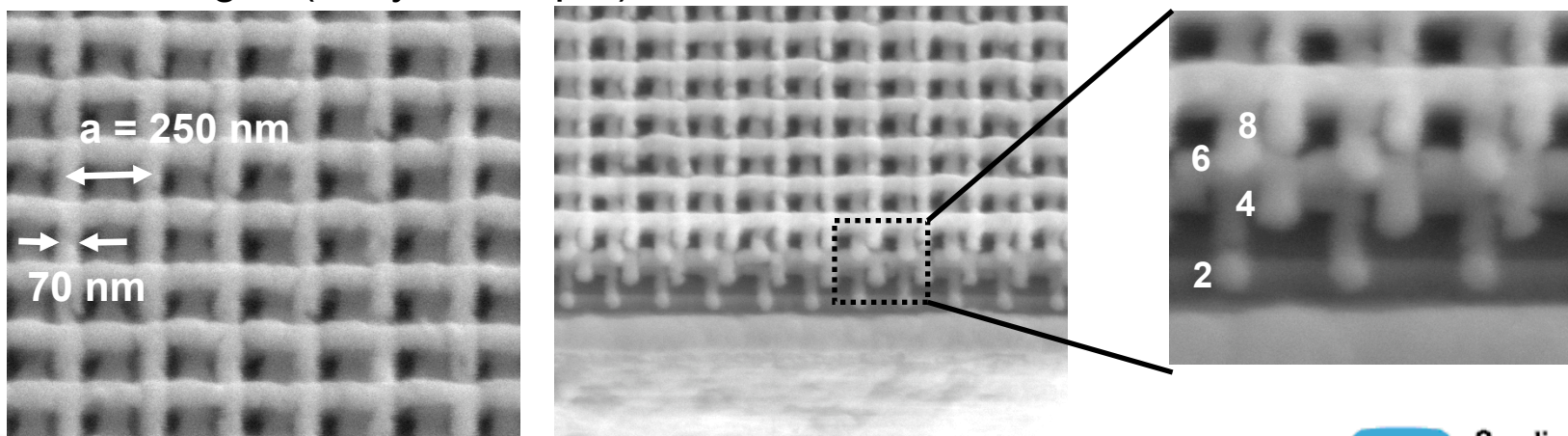
White light microscope images (5 layer sample)



TiO<sub>2</sub> index of refraction

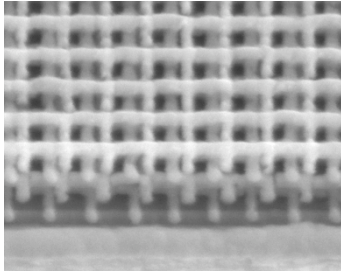


SEM images (9 layer sample)



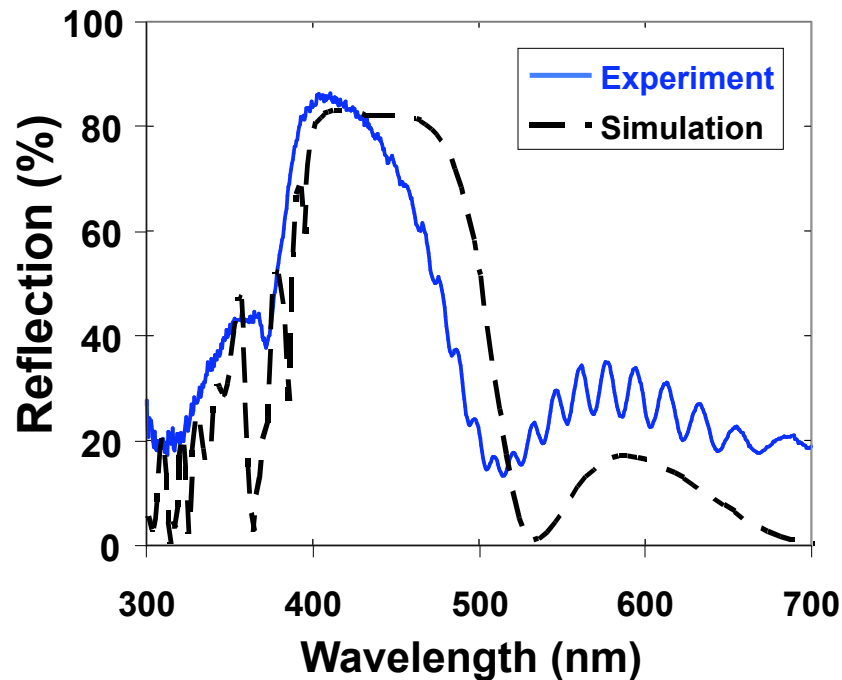
# Reflectance from 9-Layer Visible TiO<sub>2</sub> Logpile

SEM - 9 layer logpile

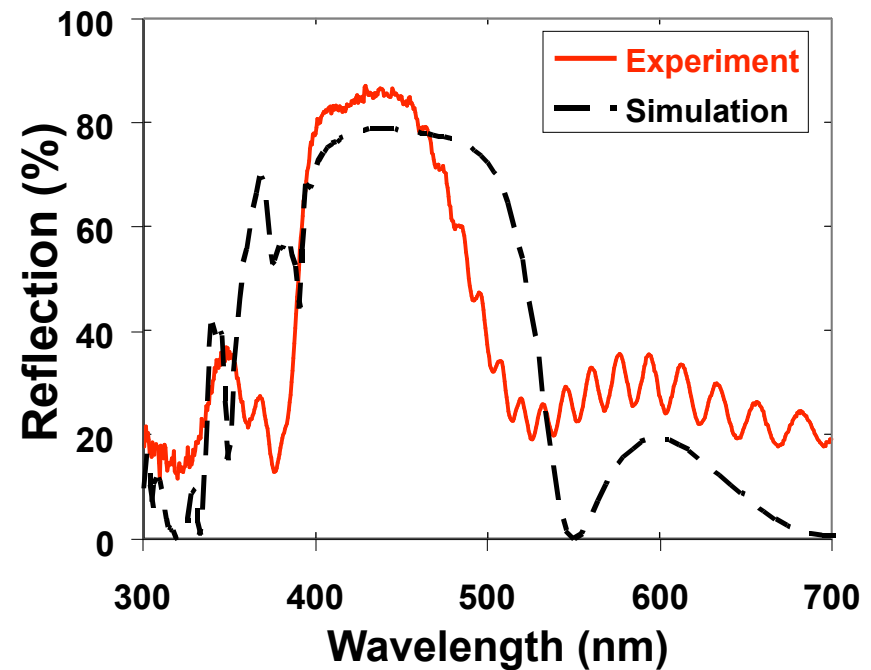


- Near normal incident reflection data
- Nine layer structure with lattice constant  $a=250$  nm
- Bandgap extends from 400 to 500 nm
- Reflection greater than 80% → excellent morphology
- Demonstrates that TiO<sub>2</sub> PCs can be used at 400 nm

Reflection- Parallel Polarization



Reflection- Perpendicular Polarization

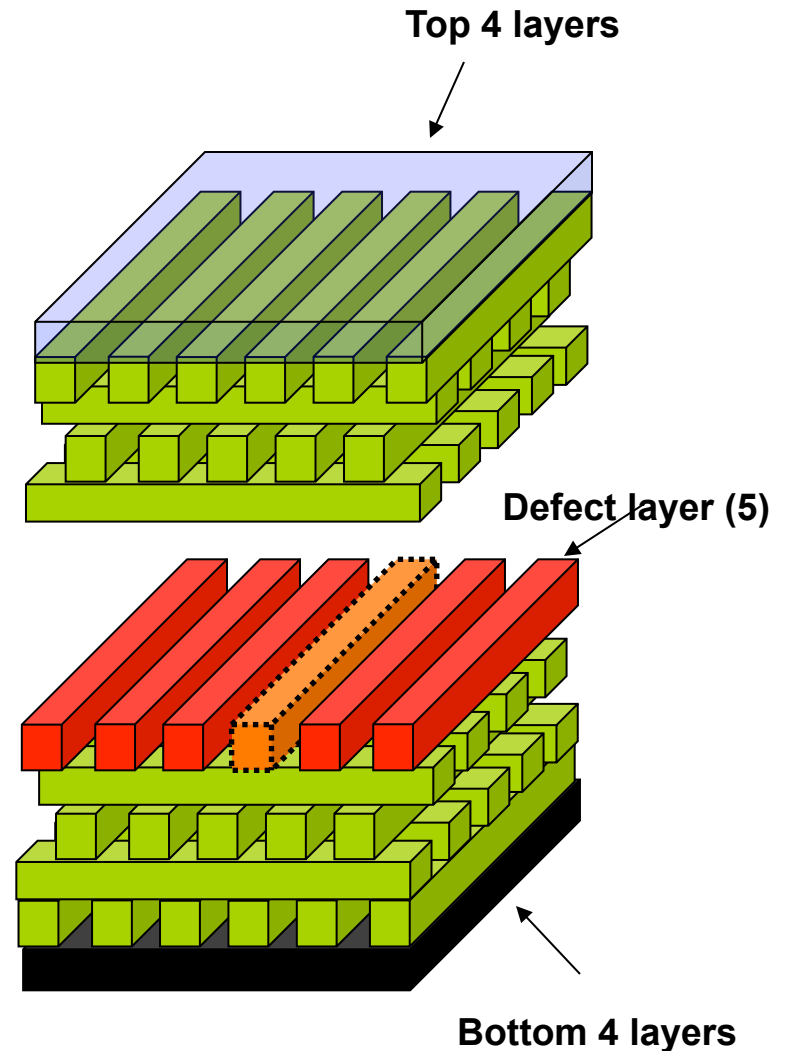




# 3D photonic crystal 'air defect' microcavity

Geometry: 9 layer structure with microcavity defect in the 5<sup>th</sup> layer

- Portions of rods removed to create 'air' defect cavities
- Fabricate bottom 5 layers first and then the top 4 layer separately on a transparent substrate ( sapphire)
- Enables introduction of light emitters (e.g. QDs) post fabrication using chemical functionalization ( already developed)
- Evaluate cavity modes: resonance frequency, Q factor
- **Small modes volumes and high Q are desired**



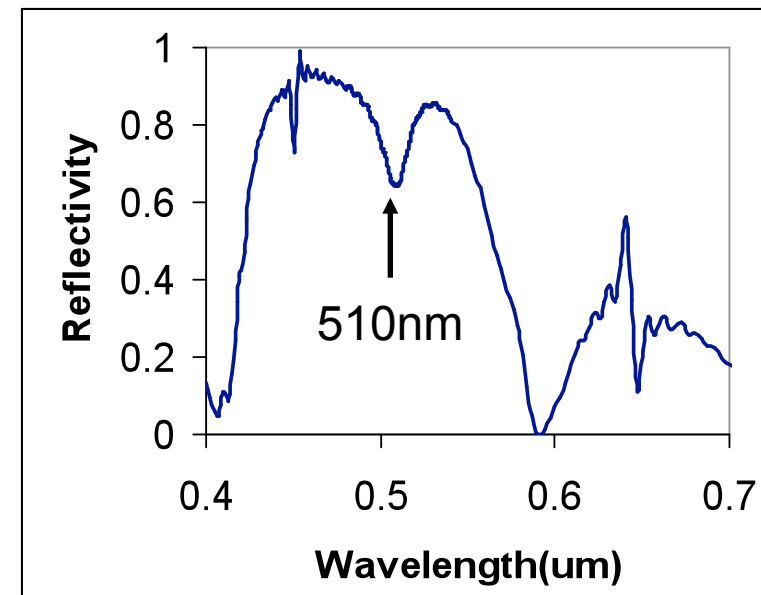
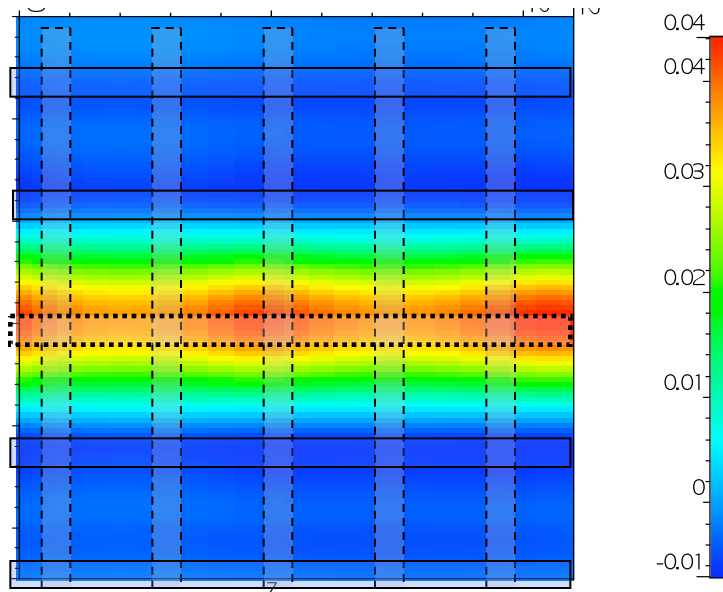
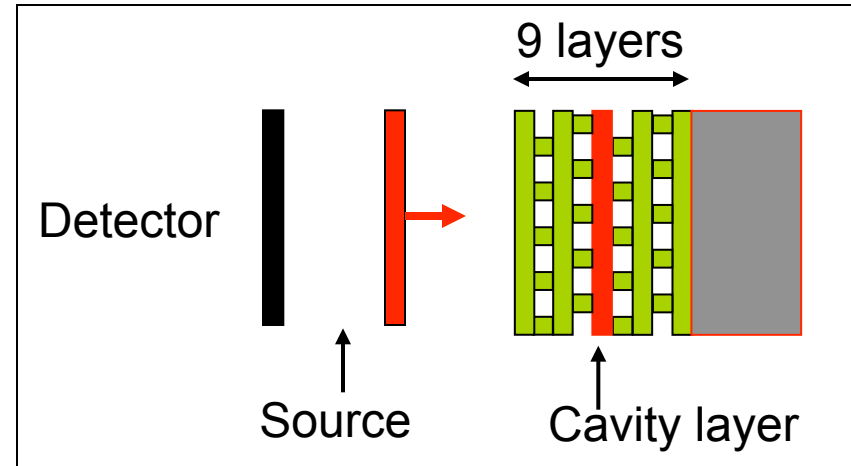
# FDTD modeling of microcavity reflectance

## FDTD conditions:

- Supercell: 5 unit cells
- Cavity defect periodic with 5 unit cells
- Periodic boundary conditions in the transverse
- Gaussian source

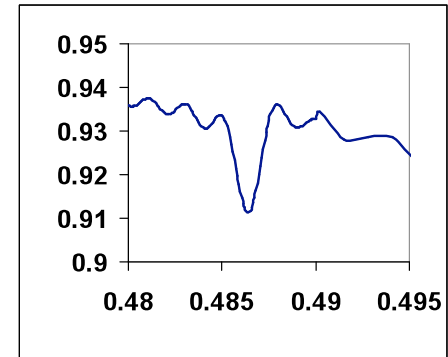
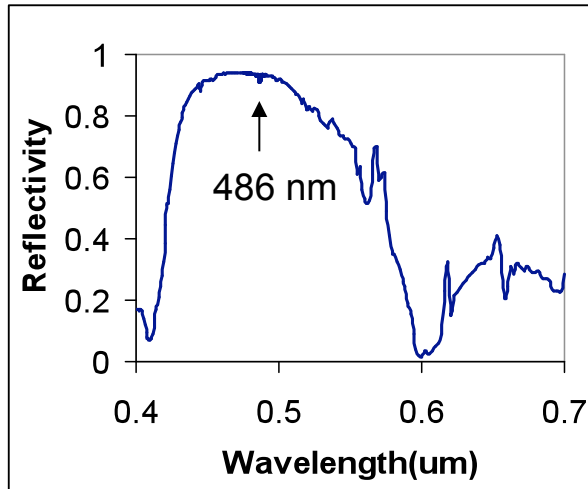
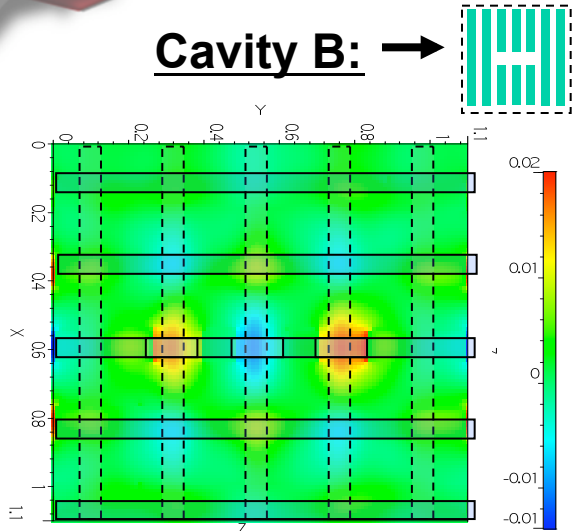
## Cavity A: Every 5<sup>th</sup> rod removed

- Q factor  $\sim 30$
- Mode volume :  $2 \cdot (l/n)^3$



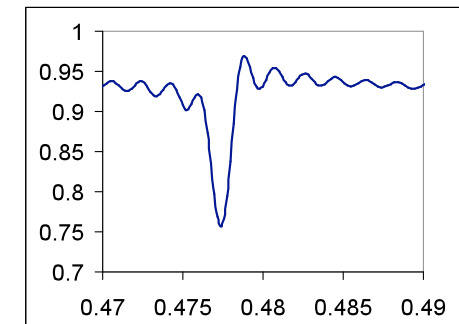
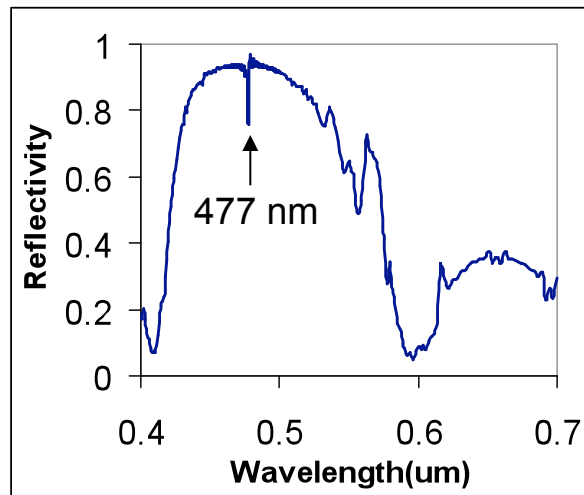
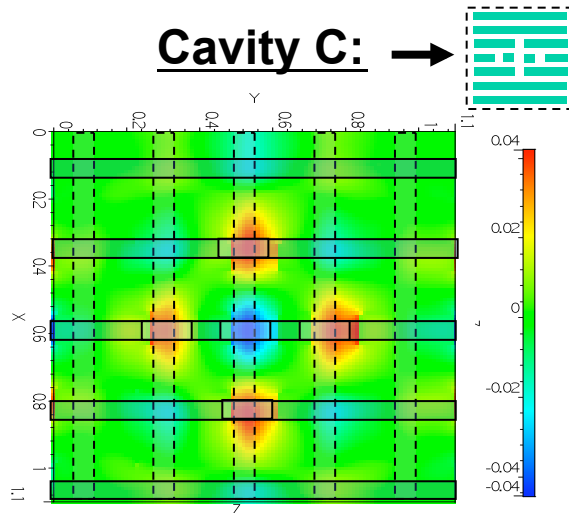
# FDTD modeling of microcavity reflectance

**Cavity B:** →



- $Q \sim 250$
- $MV : 0.25(I/n)^3$

**Cavity C:** →

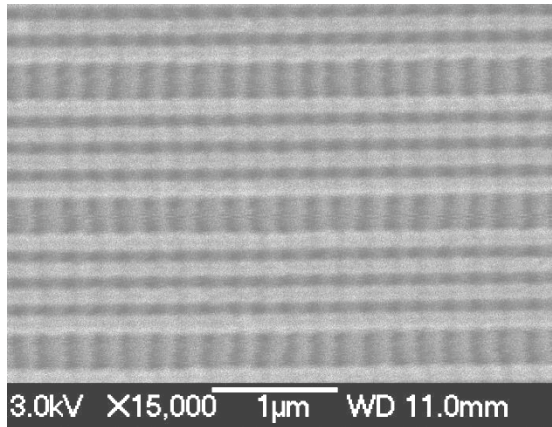


- $Q \sim 300$
- $MV : 0.42(I/n)^3$

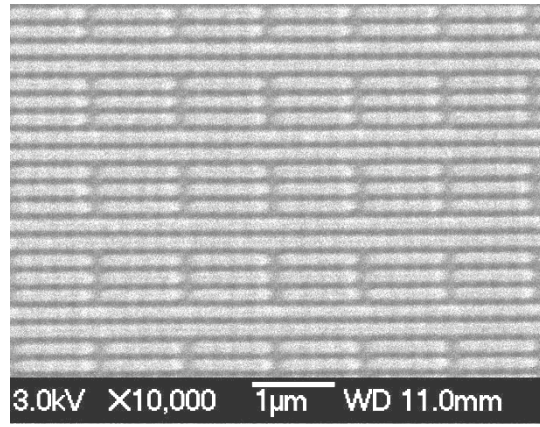


# Fabricated $\text{TiO}_2$ Photonic Crystal Cavities

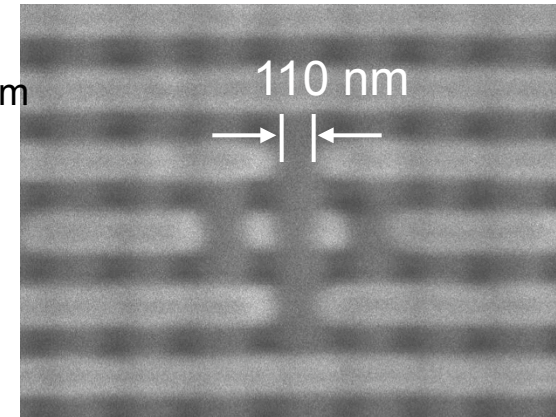
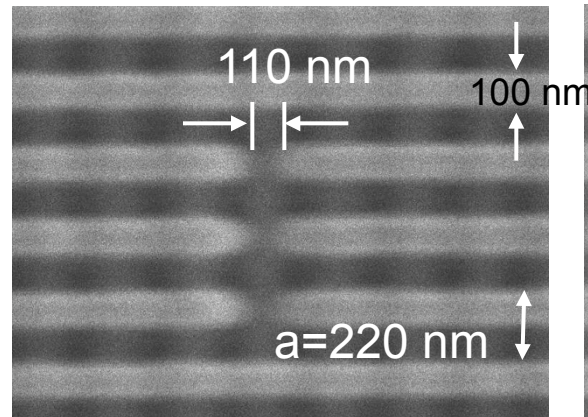
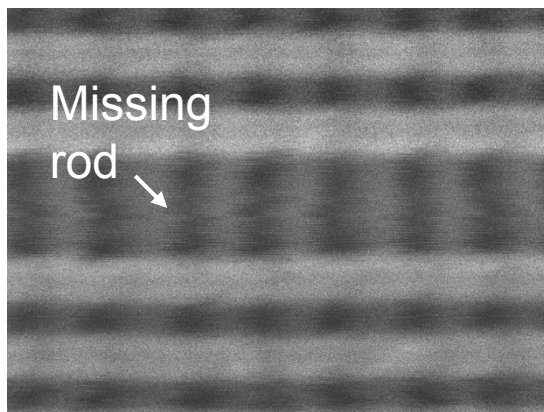
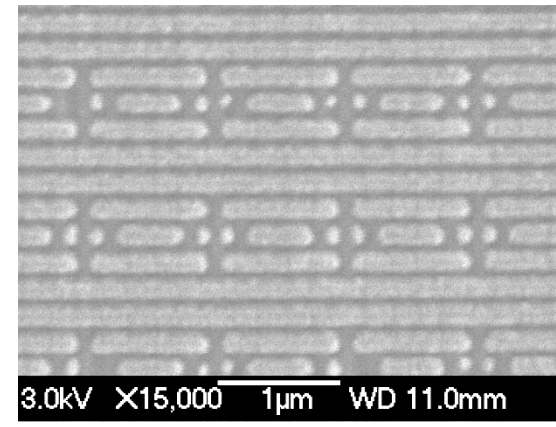
Cavity A



Cavity B



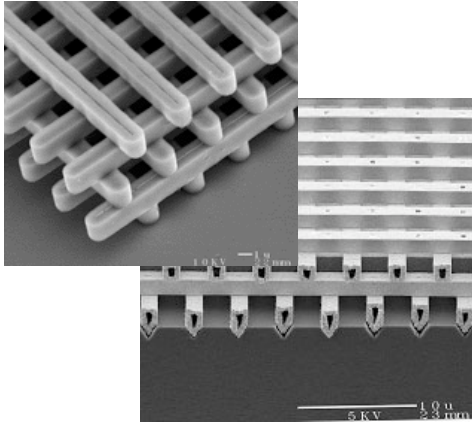
Cavity C



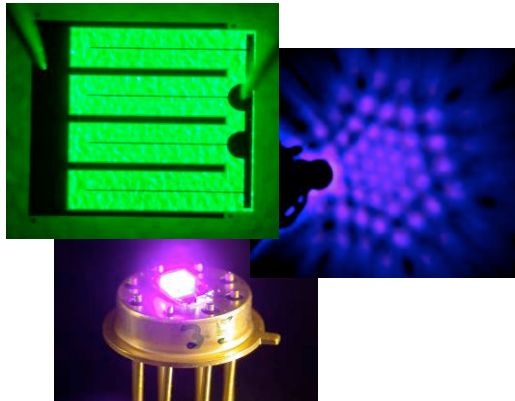


# Combine 3D photonic crystals and InGaN LEDs

## 3D photonic crystals

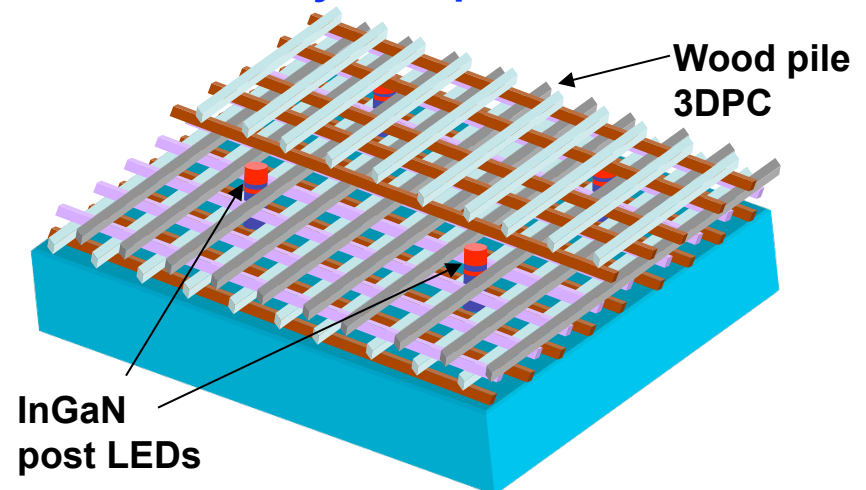


## InGaN LEDs



- Use InGaN LEDs as a test case for enhanced spontaneous emission.
- Merge InGaN LED research with 3D photonic crystal research.
- Sandia is a recognized world leader in both areas.
- Both research areas will benefit.
  - GaN is an attractive dielectric for 3D PBG work.
  - InGaN LED efficiency enhancements benefit SSL

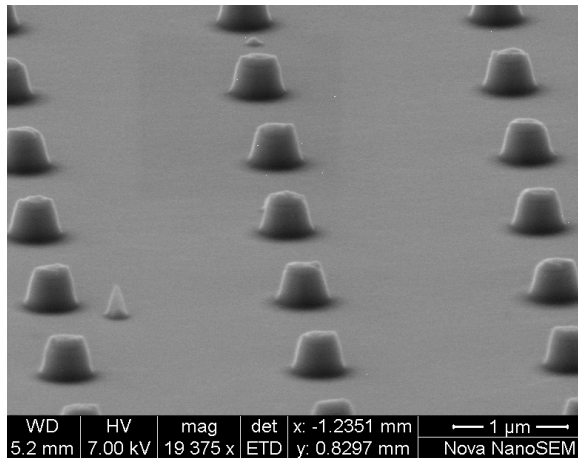
## InGaN LED array incorporated into a 3DPC



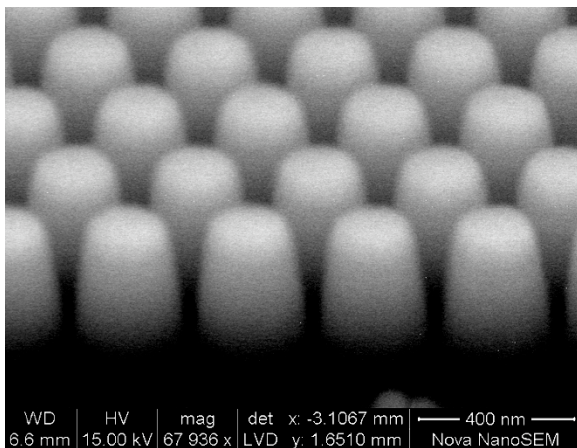


# Incorporation of emitters: InGaN nanopost LEDs

loose-packed nanopost LED array

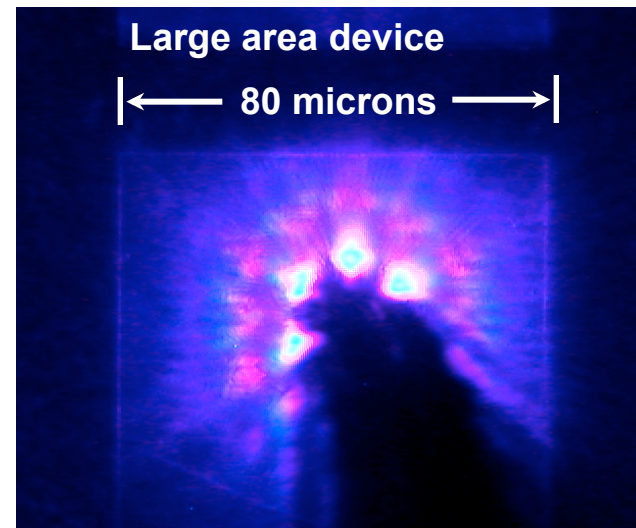


close-packed nanopost LED array



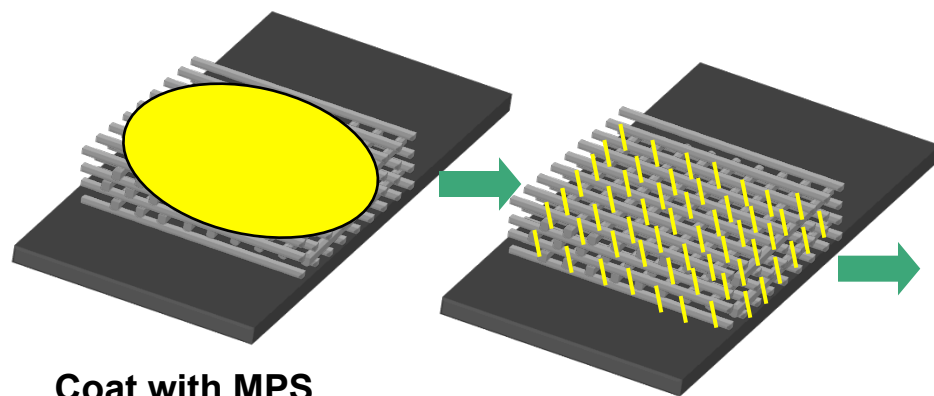
- Fabricated InGaN nanopost LEDs
- Arrays were fabricated such that a 3D logpile PC could be formed around posts.
- Difficult to electrically connect LEDs
- Original plan was to incorporate InGaN nanopost LEDs in 3D PCs
- **Better methods of emitter incorporation were developed as a part of this program**

EL from one (or a few) nanopost LEDs



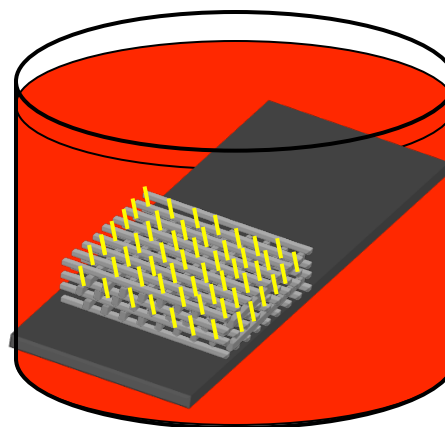
# Self-assembled Monolayer of CdSe on TiO<sub>2</sub>

1. Coat TiO<sub>2</sub> logpile with neat 3-mercaptopropyltrimethoxysilane (70 °C, 3 min)
2. Rinse with chloroform
3. Bake logpile on hot plate to form linkage (120°C, 30 min)
4. Place TiO<sub>2</sub> logpile in TOPO-capped CdSe in toluene (RT, 1 hr)

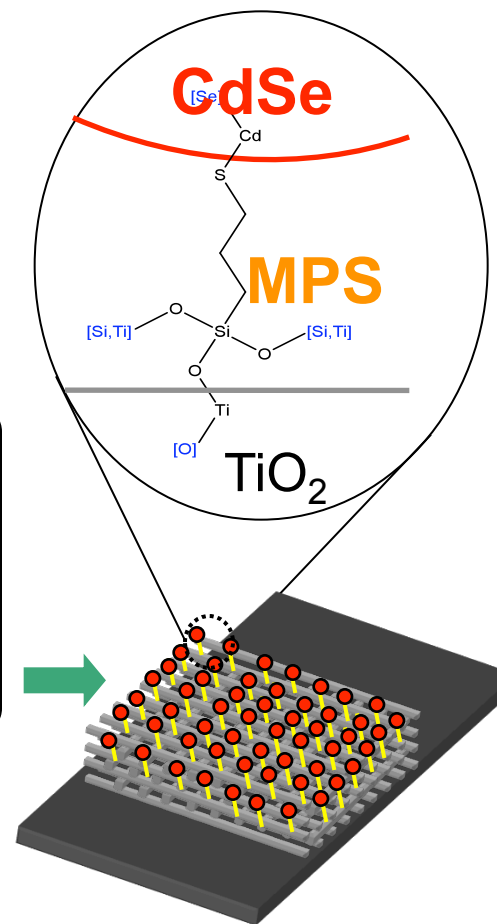


Coat with MPS

Rinse off MPS  
Bake to form self-assembled monolayer (SAM)



Submerge in CdSe suspension to exchange ligands



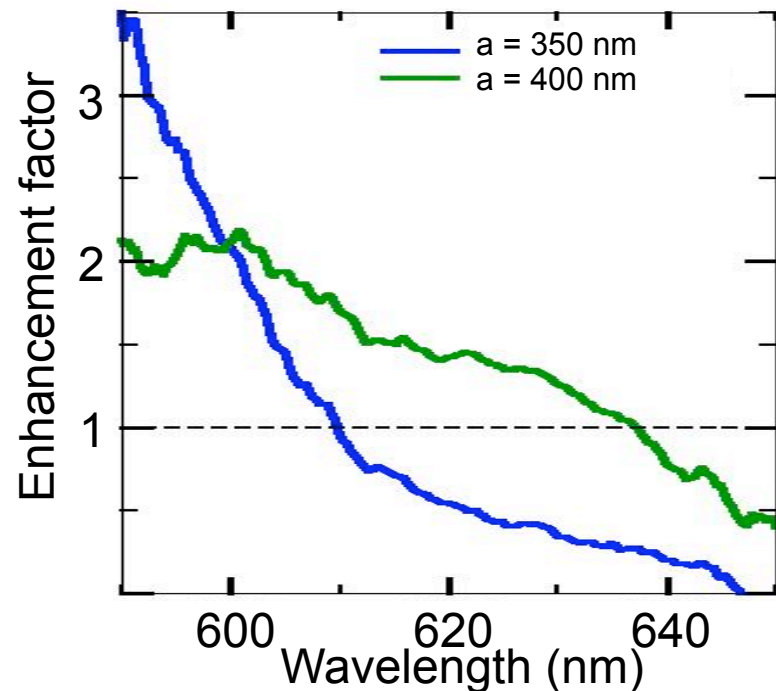
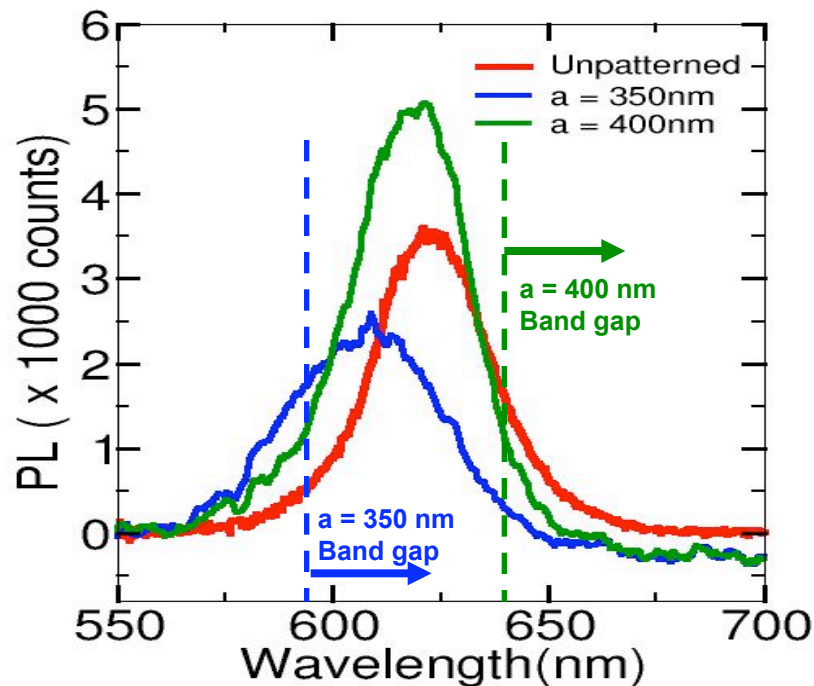
Rinse off unattached CdSe

P. Guyot-Sionnest and C. Wang, J. Phys. Chem. B, 107, 7355 (2003)  
J. Pacifico, D. Gomez, and P. Mulvaney, Adv. Mater. 17, 415 (2005)

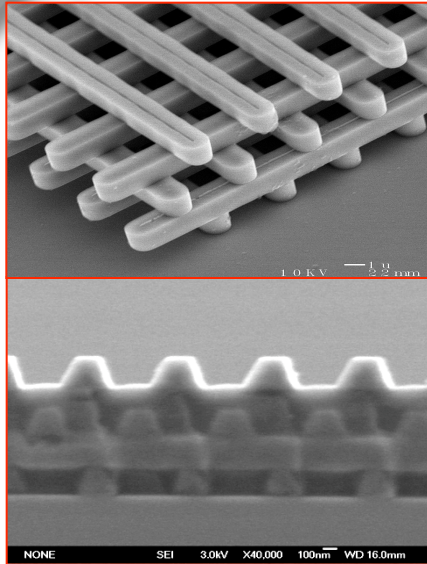


# PL Response of CdSe QDs Inside the PC

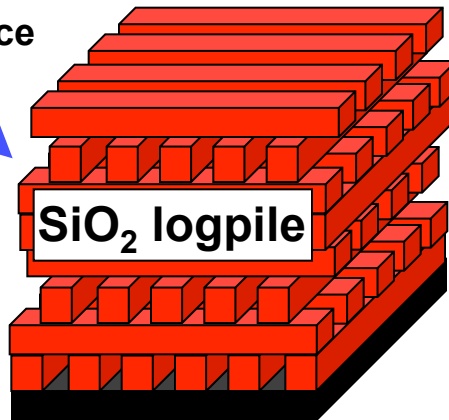
- Incorporated CdSe quantum dots into  $\text{TiO}_2$  3D logpile structures
- Developed Aerogel + quantum dot infiltration process
- PL is enhanced for 400 nm lattice constant (outside band gap)
- PL is suppressed for 350 nm lattice constant (inside band gap)
- 3D photonic crystal is effective at controlling photon emission



# Fabrication of all GaN Vis-UV Logpile PC

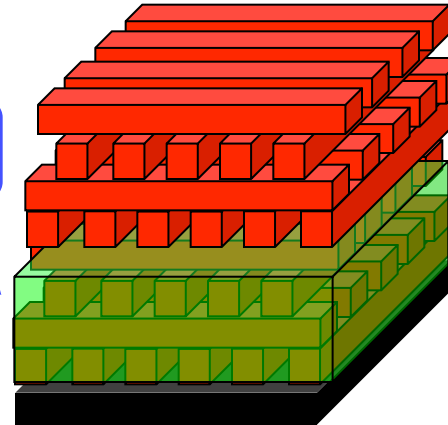


1. Fabricate Si logpile with SiO<sub>2</sub> background still in place



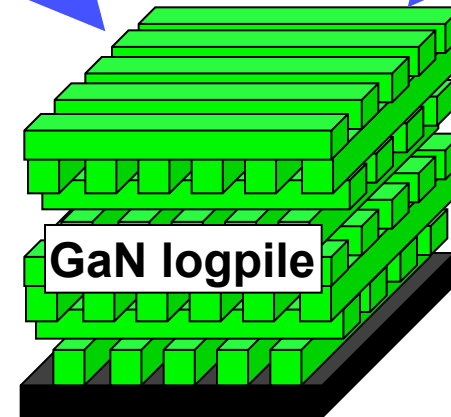
2. Etch out Si using KOH leaving SiO<sub>2</sub> skeleton in place

GaN grows uniformly throughout structure



3. Grow GaN by MOCVD

Transparent to 365nm  
Index ~ 2.5

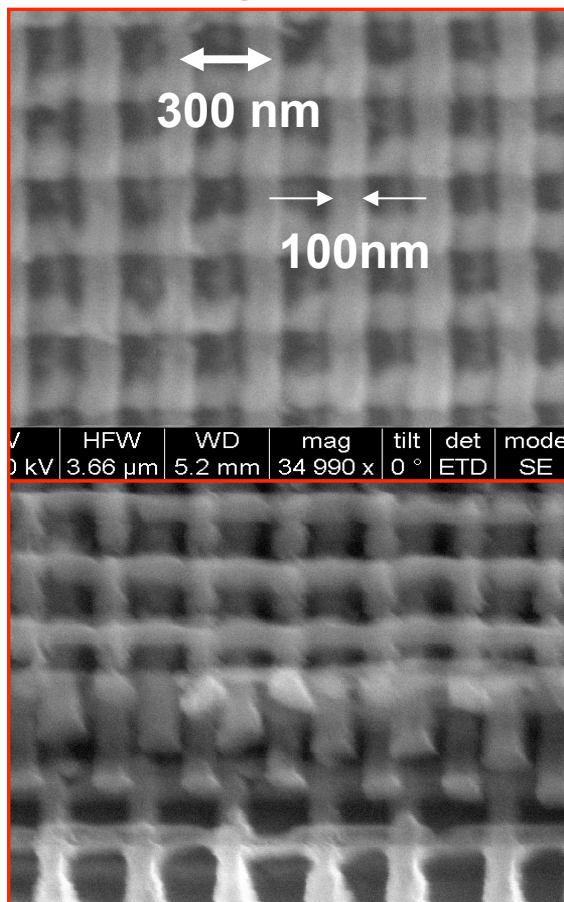


4. Remove SiO<sub>2</sub> template to leave behind GaN logpile



# All GaN Vis-UV Logpile Photonic Crystal

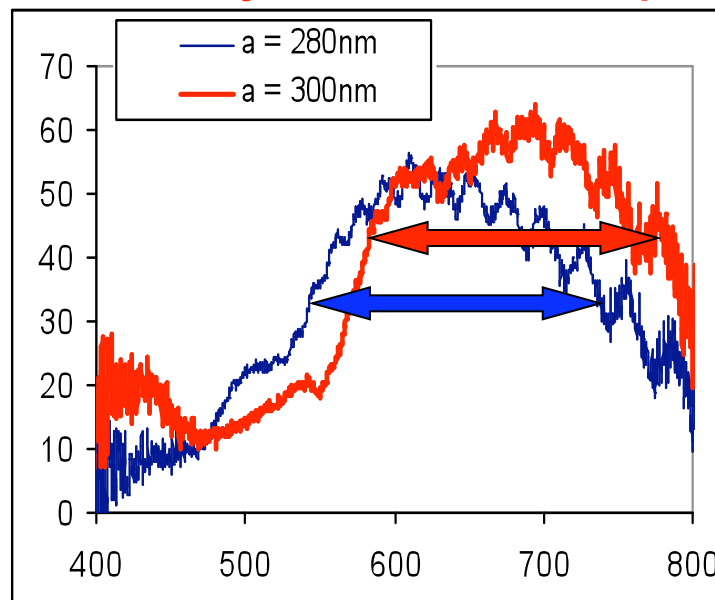
SEM images of GaN PC



## Implications of GaN logpile PC:

- Demonstrated all GaN 3D PC structure
- Important step forward for visible PCs
- Extremely good transparency across entire visible spectrum and into UV
- Potential to demonstrate shortest 3D PC
- Incorporate InGaN emitters, n-type and p-type
- Clear path to an electrically-injected 3D photonic crystal light source

Reflectivity from GaN PC sample



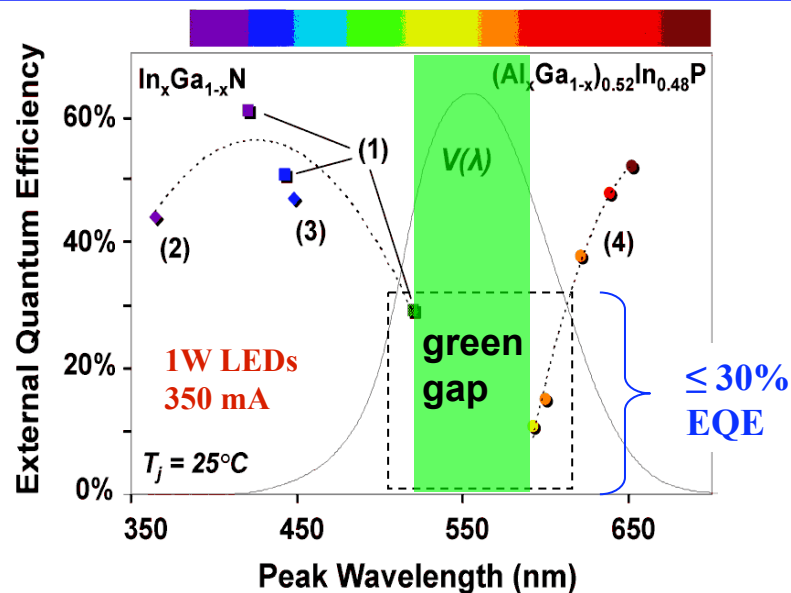


# Impact of 3D photonic crystal research

## Example Application Area:

### → High efficiency lighting (SSL)

- Efficiency gap between nitrides and phosphides (green gap)
- Utilize changes to photonic density of states to increase efficiency
- Increase radiative rate to better compete with non-radiative



## Significance of Results

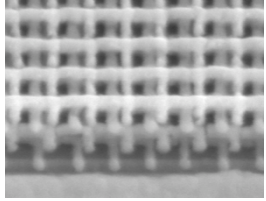
- Advance our understanding of interaction between semiconductor emitters and 3D photonic crystals.
- Develop new fabrication methods for visible 3D photonic crystals.
- Pave the way for investigation of exciting new areas of physics research:
  - Polariton dynamics, strong coupling
  - Solid state Bose-Einstein condensation
- Enable the development of advanced photon sources for applications such as optical and quantum computing.
- Control photon emission processes at a new and unprecedented level.
- Create solid state light sources with new functionality:
  - High Brightness/Efficiency
  - Single/Entangled Photon Sources
  - Directional, Compact
  - Anti-bunched Photons

# Summary

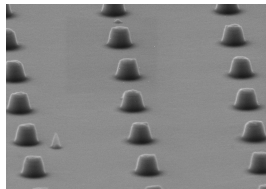
## Accomplishments:

- Developed a method of fabricating 3D logpile photonic crystal structures made from  $\text{TiO}_2$  for use in the visible.
- Incorporated GaN and quantum dot emitters in photonic crystal cavities and investigated luminescence properties.
- Demonstrated changes to luminescence intensity as well as radiative lifetime for emitters inside photonic crystal cavities
- Demonstrated control of light emission via altered photonic density of states.
- Developed a new method to fabricate UV/visible 3D photonic crystal structure made totally of GaN material.
- Funded follow-on project to investigate strong coupling and polariton condensates in GaN microcavities (BES-EFRC)
- 5 journal publications and 7 conference presentations

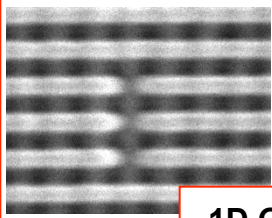
Visible 3D logpile



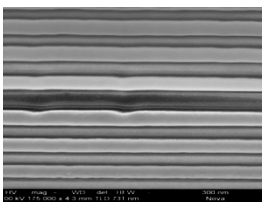
Nano-post LEDs



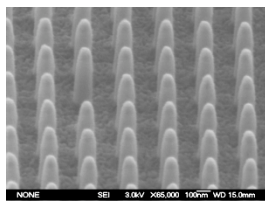
Defect cavities



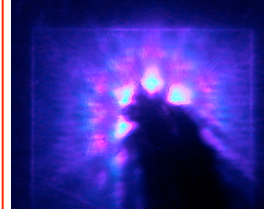
1D GaN cavity



Array of  $\text{TiO}_2$  rods



Nano-post EL



Defect cavities

